

Appl. No.: 10/644,456

Amendments to the Specification:

Please replace the paragraph [0001] with the following amended paragraph:

This application ~~relates to~~ is a divisional application of U.S. Patent Application Serial No. 09/920,257, entitled "Method of Making Photomask Material by Plasma Induction," filed August 1, 2001, in the names of Laura Ball and Sylvia Rakotoarison.